

Patent CIT.PAU.01

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

SCHERER ET.AL.

SERIAL NO.: 10/068,283

FILED: FEB. 5, 2002

FOR: DRY ETCHING AND MIRROR

DEPOSITION PROCESSES FOR SILICONE ELASTOMER

Examiner: R. McDonald

Group Art Unit: 1753

RECEIVED TC 1700

## **AMENDMENT**

Hon. Commissioner of Patents and Trademarks Washington DC 20231

Sir:

In reply to the Office Action mailed June 30, 2003, please enter the following amendments and consider the following remarks.

Claims 1 – 20 were original in the application. Claims 2 – 13 have been indicated as allowable. Claim 1 has been amended. Claims 16 - 20 were withdrawn. Claims 21 - 25 are new. Therefore, claims 1 - 15 and 21 - 25 are submitted for examination on the merits in amended form.

A check for the appropriate fee for excess claims for a small entity is included.

The Office is also authorized to charge all fees under 37 CFR § 1.17, or all required extension of time fees or any deficit and credit any surplus in such fees to our depermandation account #01-1960.

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